

APR 3 0 2001

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Form PTO-1443 (Modified)

LIST OF PATENTS  
AND PUBLICATIONS  
APPLICANT'S INFORMATION  
DISCLOSURE STATEMENT  
(Use several sheets if necessary)ATTY.DOCKET NO.  
1978ASERIAL NO.  
09/676,161APPLICANT  
Brian G. Morin et al.

FILING DATE September 29, 2000

GROUP 1771

## U.S. PATENT DOCUMENTS

EXAMINER INITIALS	IDENTIFIER	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB-CLASS	FILING DATE
	AA	3,902,299	9/2/75	Zeidell	53	431 EC	7/2/73
	AB	3,897,206	7/29/75	Kearney	8	120	12/27/72
	AC	4,888,229	12/19/89	Paley et al.	428	192	4/8/88
	AD	5,069,735	12/3/91	Reynolds	156	497	6/4/90
	AE	5,229,181	7/20/93	Daiber et al.	428	58	10/30/90
	AF	5,271,995	12/21/93	Paley et al.	442 428	224 221	2/23/90
	AG	5,320,900	6/14/94	Oathout	442 428	408 288	8/10/93
	AH	5,460,655	10/24/95	Pisacane et al.	134	6	1/27/94
	AI	5,736,469	4/98	Bhattacharjee et al.	442	110	
	AJ						
	AK						
	AL						

## FOREIGN PATENT DOCUMENTS

EXAMINER INITIALS	IDENTIFIER	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION: YES NO
	(CONT. FROM ABOVE)					NO	

## OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

Perovic, Aleksandra; "Morphological instability of poly(ethylene terephthalate) cyclic oligomer crystals"; *Journal of Materials Science* 20 (1985); pp. 1370-1374

Perovic, A. and Sundararajan, P. R.; "Crystallization of Cyclic Oligomers in Commercial Poly(ethyleneterephthalate) Films"; *Polymer Bulletin* 6 (1982); pp. 277-283

Cimecioglu, A.L. et al.; "Properties of Oligomers Present in Poly(ethylene Terephthalate)"; *Journal of Applied Polymer Science*, Vol. 32 (1986); pp. 4719-4733

Institute of Environmental Sciences, Contamination Control Division; *Evaluating Wiping Materials Used in Cleanrooms and Other Environments* (IES-RP-CC004.2)

Examiner

Date Considered

5/2002

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.